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Room-temperature multiferroic hexagonal LuFeO₃ films

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The crystal and magnetic structures of single-crystalline hexagonal LuFeO₃ films have been studied using x-ray, electron and neutron diffraction methods. The polar structure of these films are found to persist up to 1050 K; and the switchability of the polar behavior is observed at room temperature, indicating ferroelectricity. An antiferromagnetic order was shown to occur below 440 K, followed by a spin reorientation resulting in a weak ferromagnetic order below 130 K. This observation of coexisting multiple ferroic orders demonstrates that hexagonal LuFeO₃ films are room-temperature multiferroics.

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The coexistence and coupling of ferroelectric and magnetic orders in multiferroic materials promise many improvements over singly ordered ferroic materials for next generation applications in information technology, sensing, and actuation.[1–3] For widespread implementation of this technology, coexistence of long range magnetic and electric orders at room temperature will be required; at present, there is only one material, BiFeO₃, known to exhibit ferroelectricity and antiferromagnetic order above room temperature.[4] Hexagonal ferrites (h-RFeO₃, R=Sc, Y, Ho-Lu) are expected to be ferroelectric due to the polar structure that lies at the origin of the ferroelectricity of YMnO₃ above room temperature ($T_C \approx 1000$ K).[5] In fact, the evidence of ferroelectricity has been found in h-YbFeO₃ films below 470 K.[6] Antiferromagnetic spin structures involving a triangular arrangement of the moments in the *a-b* plane are expected in h-RFeO₃ due to the structural symmetry.[7] Despite the frustration created by the triangular lattice, the strong interactions between the Fe³⁺ sites due to high spin and large Fe-O interactions [8, 9] are expected to greatly increase the magnetic ordering temperature of h-RFeO₃ compared with that of RMnO₃ ($T_N \approx 100$ K)[10]. This makes h-RFeO₃ promising candidates to be room-temperature multiferroics.

Here we focus on LuFeO₃, which is known to crystallize in both orthorhombic (o-LuFeO₃) and presently investigated hexagonal (h-LuFeO₃) structures. Orthorhombic LuFeO₃ is stable in bulk with a non-polar Pbnm structure and exhibits C-type antiferromagnetism below $T_N = 620$ K.[8] In contrast, a polar P6₃cm structure has

been found in bulk (metastable) and thin film h-LuFeO₃ at room temperature.[11, 12] A weak ferromagnetic order below 120 K has been recently reported in h-LuFeO₃ films.[13] While the polar structure of h-LuFeO₃ suggests ferroelectricity, the structural phase transitions have not been investigated. More importantly, the magnetic ordering temperature (the aforementioned key factor of the room-temperature multiferroicity in h-RFeO₃) and the detailed magnetic structure have not been unambiguously determined in h-LuFeO₃. In this work, we show using a combined investigation of neutron scattering and magnetometry that an antiferromagnetic order occurs in h-LuFeO₃ films below $T_N = 440$ K, followed by a spin reorientation below $T_R = 130$ K as the origin of the previously observed weak ferromagnetic order. We also show that the polar structure P6₃cm in h-LuFeO₃ films persists up to 1050 K according to the electron and x-ray diffraction measurements. The switchability of the polar behavior is observed using piezoelectric force microscopy at room-temperature, providing strong evidence of ferroelectricity. These observations demonstrate that the h-LuFeO₃ films are multiferroic at room temperature.

Hexagonal LuFeO₃ films (20-60 nm) have been grown epitaxially using pulsed laser deposition both onto α -Al₂O₃ (001) substrates and onto sputtered epitaxial Pt films (30 nm) on α -Al₂O₃ (001) substrates.[14] The film structure was determined *in-situ* by reflection high energy electron diffraction (RHEED) and *ex-situ* by x-ray diffraction (XRD) and transmission electron microscopy (TEM) data.[15] Piezoresponse force microscopy (PFM) was studied on the h-LuFeO₃/Pt/Al₂O₃ films. The neu-

tron diffraction experiments were carried out on a stacked h-LuFeO₃ films on the HB1A thermal triple axis spectrometer at the High Flux Isotope Reactor, Oak Ridge National Laboratory. The temperature dependence of the magnetization was measured using a superconducting quantum interference device (SQUID) magnetometer. The temperature dependence of x-ray spectroscopy was studied using polarized synchrotron at beam line 4-ID-C at the Advanced Photon Source.

As shown in Fig. 1(a), the x-ray diffraction data indicate that the h-LuFeO₃ films are grown along the [001] direction without detectable impurity phases. The RHEED image shows intense diffraction streaks separated by weak streaks (Fig. 1(b)), which can be understood in terms of the detailed structure of h-LuFeO₃. The P6₃cm structure can be viewed as a result of the distortions from a non-polar P6₃/mmc structure with alternating LuO₂ and FeO layers (Fig. 2 (a)). The distortions include the rotations of the FeO₅ trigonal bipyramids with propagation vector $\vec{K}=(1/3,1/3,0)$ corresponding to a $\sqrt{3}\times\sqrt{3}$ reconstruction in the *a-b* plane (tripling the unit cell) and the displacements of the Lu atoms along *c*-axis with $\vec{K}=(0,0,0)$ which breaks the inversion symmetry and allows for an electric polarization along the *c*-axis (Fig. 2 (a-d)).[5] The RHEED pattern is in perfect agreement with the $\sqrt{3}\times\sqrt{3}$ reconstruction in the *a-b* plane. From the streak separations, the in-plane lat-

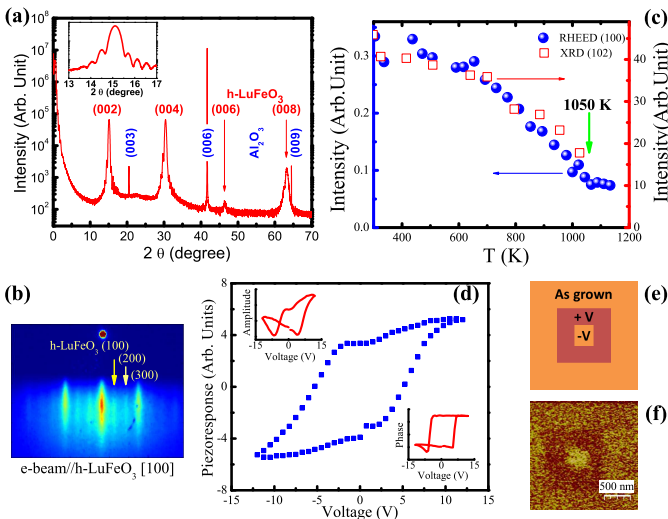


FIG. 1: (Color online) The structural characterizations of the h-LuFeO₃ films using RHEED and XRD. (a) A typical θ - 2θ scan of an h-LuFeO₃ film. The inset shows the close-up view of the h-LuFeO₃ (002) peak. (b) A RHEED image of the h-LuFeO₃ film with electron beam along Al₂O₃ and h-LuFeO₃ [100] direction. (c) Intensities of RHEED (100) peak and XRD (102) peak as functions of temperature. (d) PFM response displaying square-shaped hysteresis loop. The amplitude and phase are shown in the insets. (e) Schematic of written domain pattern with DC voltage ($V = 20$ V_{dc}). (f) PFM image of the same region without DC voltage.

tice constants of the h-LuFeO₃ films can be estimated as $a=5.96 \pm 0.1$ Å, consistent with the value of the bulk P6₃cm structure.[12] Hence the indices of the diffraction streaks can be assigned using a P6₃cm unit cell,[16] as indicated in Fig. 1(b), suggesting an epitaxial relation Al₂O₃ [100]/h-LuFeO₃ [100], in agreement with the XRD characterization.[17]

Temperature dependent RHEED and XRD have been carried out to study the robustness of the polar structure. As shown in Fig. 1(c), the intensity of the RHEED (100) peak (normalized with that of the (300) peak) is displayed as a function of temperature. A clear transition at approximately 1050 (+/-50) K is observed from the RHEED (100) peak intensity, indicating a structural transition. The intensity of the XRD (102) peak follows the trend of the RHEED (100) peak closely, although the transition is not observed due to limited temperature range.[18]

Symmetry analysis predicts three possible routes for the transition from a P6₃cm ($Z=6$, polar) structure to a P6₃/mmc ($Z=2$, non-polar) structure, where Z is the number of formula unit per unit cell (Fig. 2(e)).[5, 19] According to the kinetic theory, the diffraction intensities differ dramatically for (100) and (102) peaks for different structures:[17] Firstly, both (100) and (102) peaks vanish for structures with $Z=2$ unit cells. Secondly, for a P6₃/mcm structure, the diffraction intensity for (100) and (102) peaks should be similar, while for a P6₃cm structure, the (100) peak should be much weaker than that of the (102) peak. Therefore, the diminishing in-

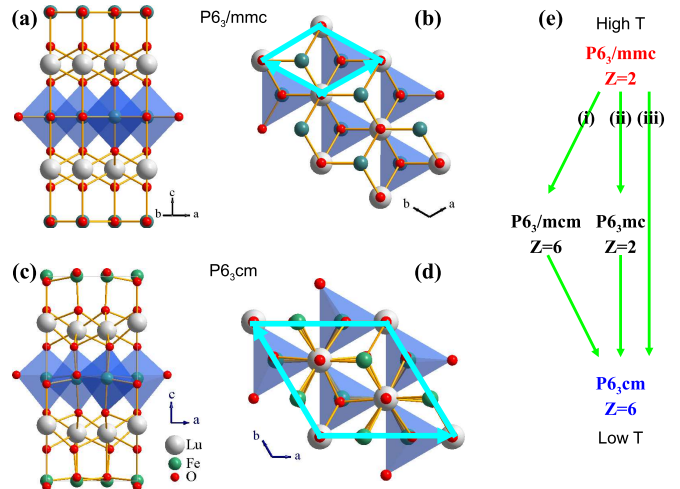


FIG. 2: (Color online) The schematic representation of P6₃/mmc and P6₃cm structures and the possible transition routes. (a) and (b) are the P6₃/mmc structure viewed from [120] and [001] direction respectively. (c) and (d) are the P6₃cm structure viewed from [100] and [001] direction respectively. The bold lines in (b) and (d) indicate the unit cells in the *a-b* plane. (e) Possible routes from P6₃/mmc to P6₃cm structures.

tensities of the RHEED (100) peak and XRD (102) peak suggest a transition from a $Z=6$ to a $Z=2$ structure. The fact that the intensity of the XRD (102) peak follows that of the RHEED (100) peak indicates the structure of the h-LuFeO₃ films at $T < 1050$ K belongs to a $P6_3cm$ structure, i.e. no intermediate $P6_3/mcm$ structure involved. Hence the RHEED and XRD data suggest that the polar structure $P6_3cm$ of the h-LuFeO₃ films persists up to at least 1050 K.

To assess possible ferroelectricity in our h-LuFeO₃ films given the polar structure, we studied the switchability of the h-LuFeO₃ films (30 nm) on Pt-buffered Al₂O₃ using PFM.[20] Here we used Band Excitation Switching Spectroscopy with an ac imaging voltage of 2 V_{ac} and a maximum switching voltage of 12 V_{dc} to measure the piezoresponse loops.[21] A metal coated tip (Nanosensors) is used. We measured three piezoresponse loops at each position of a 10×10 point grid in a $3 \times 3 \mu m^2$ area and extracted the average switching behavior as displayed in Fig. 1(d). The piezoelectric loops show square-shaped loops with switching voltages around 5 V_{dc} and -7 V_{dc} , which are indicative of ferroelectric switching. Further evidence of ferroelectric switching was obtained in decoupled write/read PFM processes, i.e. poling (write) domain pattern with DC voltage ($\pm 20 V_{dc}$) on the h-LuFeO₃ film as shown in Fig. 1(e), then visualizing (read) the same region with only AC imaging voltage. As shown in Fig. 1(f), the written domain patterns is clearly visible in the PFM image. Furthermore, the patterns persist at least two hours without any visible decay in domain contrast.[17]

Now that the strong evidence of the room-temperature ferroelectricity in h-LuFeO₃ films is obtained, we investigate how robust the magnetic ordering is. Neutron diffraction experiments were carried out to study the magnetic order of h-LuFeO₃ films. The films were aligned in the $(h\ 0\ l)$ diffraction plane in a closed-cycle refrigerator. At low temperature, several Bragg peaks were clearly observed. As shown in Fig. 3 (a) and (b), the (102) peak intensity drops as the temperature increases up to approximately 440 K while for the (100) peak the transition occurs at approximately 130 K (Fig. 3 (c) and (d)). In contrast, the change of the diffraction peaks (300) and (004) with temperature is minimal between 4 K and 450 K.[17] In addition to neutron diffraction, measurements using SQUID magnetometer revealed that the zero-field-cool (ZFC) magnetization and field-cool (FC) magnetization split at 130 K under magnetic field along the c -axis, indicating the appearance of a ferromagnetic component along the c -axis (Fig. 3 (d) inset).

Since h-LuFeO₃ is isomorphic with RMnO₃ and their magnetic structures can be characterized with the same propagation vector $\vec{K}=(0,0,0)$ (meaning magnetic unit cell is the same as the structural unit cell), we can analyze the magnetic structure of h-LuFeO₃ following the symmetry analysis in RMnO₃. [7, 22–24] In this case, the

Bragg peaks (102) and (100) are in principle coming from a combination of nuclear and magnetic diffractions. However, our structural characterizations do not indicate any clear transition close to 440 K (Fig. 1 (c)), which is consistent with the fact that in RMnO₃ the magnetic diffraction constitutes the majority of the intensity for (102) peak.[7] Therefore, the transition at 440 K corresponds to the appearance of a long range antiferromagnetic order. Taking $T_N=440$ (± 10) K, one can fit between $200\text{ K} < T < 440\text{ K}$ the peak intensity using $I = I_n + I_m(1 - T/T_N)^\alpha$ where I_n and I_m are the nuclear and magnetic contributions of the intensity respectively. The result shows $\alpha=0.46 \pm 0.08$, falling well in the reported value range of YMnO₃. [25, 26] The fit for (100) peak intensity gives a larger value $\alpha = 0.69 \pm 0.15$. The development of a ferromagnetic component below $T_R=130$ (± 1) K suggests that the system displays a second magnetic phase by a spin reorientation which is consistent with our x-ray magnetic dichroism measurements[17].

The possible magnetic structures of the h-LuFeO₃ films can be assigned by taking both the neutron diffraction and the magnetization measurements into account. Fig. 4 summarizes the possible magnetic structures with the propagation vector $\vec{K}=(0,0,0)$ in h-LuFeO₃, where Γ_1 , Γ_2 , Γ_3 and Γ_4 are irreducible representations (IR) of the $P6_3cm$ group. We notice that the only IR that allows for a ferromagnetic component along c -axis is Γ_2 . [7] There-

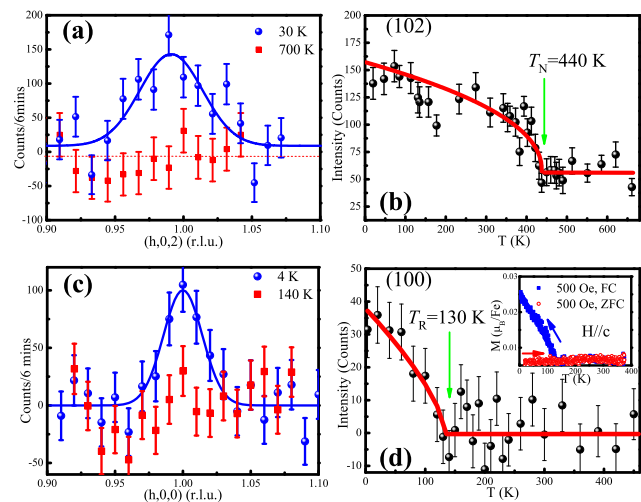


FIG. 3: (Color online) Magnetic Bragg peaks and the temperature dependence of their intensities from neutron diffraction. (a) and (c) are the diffraction intensity profile near the (102) and (100) magnetic Bragg points respectively. The lines are the Gaussian fits. (b) and (d) are the temperature dependence of the (102) and (100) magnetic Bragg peak intensities respectively. The curves in (b) and (d) are fits to the data points (see text). The inset in (d) shows the temperature dependence of the magnetization in ZFC and FC processes with the magnetic field along the c -axis.

fore the magnetic structure at temperature $T < T_R$ has to include Γ_2 , mixed with Γ_1 which contribute to the magnetic diffraction near (100)[17, 27, 28]. For the magnetic structure at temperatures $T_R < T < T_N$, Γ_1 and Γ_3 can be ruled out since Γ_1 and Γ_3 will lead to a substantial intensity of magnetic diffraction near (100)[17, 27], which actually disappears at $T > T_R$. Therefore, the candidate magnetic structures capable of describing the magnetic structures at temperatures $T_R < T < T_N$ are Γ_2 or Γ_4 .

Assuming that the ferromagnetic moment is coming from the Dzialoshinskii-Moriya (DM) interaction,[7, 13, 29–32] the effective Hamiltonian is $H_{DM} = -\sum_{i,j} \vec{D}_{i,j} \cdot (\vec{S}_i \times \vec{S}_j)$, where \vec{S}_i (\vec{S}_j) is the spin on site i (j), and $\vec{D}_{i,j}$ is the interaction coefficient. The spin canting toward the c -axis allows a slight reduction of the spin-spin angles from 120 degree, lowering energy according to the DM interaction, while keeping the in-plane projections of spin-spin angles 120 degree. In principle, the interaction coefficients $\vec{D}_{i,j}$ do not change dramatically with temperature. Since the spin structure Γ_2 generates a ferromagnetic component at $T < T_R$, the presence of Γ_2 at $T_R < T < T_N$ would also generate a similar ferromagnetic component which was not observed. Therefore, the only probable spin structure is Γ_4 at $T_R < T < T_N$.

Our results in h-LuFeO₃ films are distinct from previous reports in the clear observations of polar structure up to 1050 K and antiferromagnetism up to 440 K, the

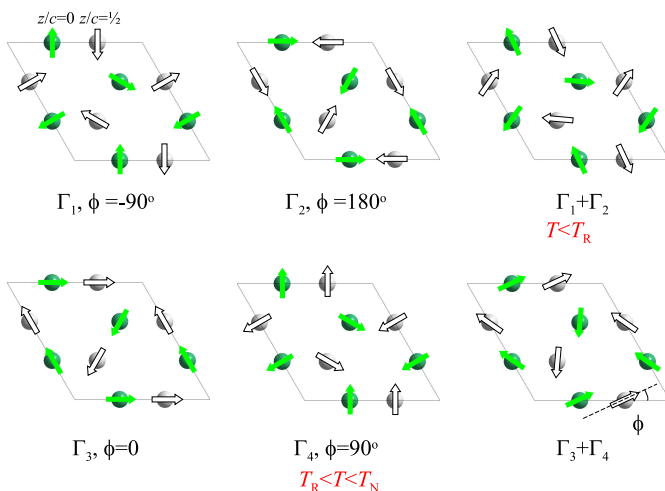


FIG. 4: (Color online) The possible magnetic structures of Fe^{3+} sites in $P6_3cm$ crystallographic structure and the assignments of magnetic structures for h-LuFeO₃. The darker (lighter) balls represent Fe^{3+} sites at $z/c=0$ ($z/c=1/2$) and the arrows indicate the magnetic moment orientation. Γ_1 (Γ_3) and Γ_2 (Γ_4) are related by the in-plane rotation angle ϕ . The Γ_1 (Γ_2) and Γ_3 (Γ_4) are a homometric pair, meaning indistinguishable in our neutron scattering measurement. The magnetic structure of h-LuFeO₃ takes the form Γ_2 , mixed with Γ_1 at $T < T_R$ and Γ_4 at $T_R < T < T_N$.

latter of which is difficult to detect using magnetization measurements alone, especially with the strong paramagnetic background from the YSZ substrates.[11, 13, 17] In principle, the magnetic ordering temperature in h-LuFeO₃ can be affected by the following factors: the exchange interaction between the Fe^{3+} sites, which is supposed to be large, as indicated by the high T_N (620 K) in o-LuFeO₃:[8] the triangular spin lattice which creates the frustration and is supposed to lower the long range spin ordering temperature:[8, 33–36] and the magnetic anisotropy energy which affects the spin orientation and is responsible for relaxing the frustration and causing the long range magnetic order.[35, 36] Clearly, future investigations on the interplay between these factors will be needed to account for the high magnetic ordering temperature in h-LuFeO₃.

In conclusion, we have demonstrated the coexistence of ferroelectricity and magnetic order at room temperature in h-LuFeO₃ films. The polar structure and the antiferromagnetic order of the films persist up to 1050 K and 440 K respectively. Besides the room temperature multiferroicity, a spin reorientation resulting in the Γ_2 magnetic structure below $T_R=130$ K is found as the origin of the net magnetic moment collinear with the electric polarization which suggests a possible linear magnetoelectric coupling.[37] The Γ_2 magnetic structure also allows for a uniaxial alignment of the non-zero R^{3+} magnetic moments and a large net magnetic moment along the c -axis in h-RFeO₃; this is observed in h-YbFeO₃ ($\approx 3\mu_B$ /formula unit).[6, 38] Therefore, future investigations should aim at tuning the spin reorientation up to room temperature or changing spin structure to Γ_2 right below T_N . This approach should render hexagonal ferrites with magnetic R^{3+} the desirable multiferroic properties: large electric and magnetic polarizations as well as linear magnetoelectric couplings at room temperature.

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- [1] H. Schmid, *Ferroelectrics* **162**, 317 (1994).
- [2] D. Khomskii, *Physics* **2**, 20 (2009).
- [3] N. A. Spaldin, S. W. Cheong, and R. Ramesh, *Physics Today* **63**, 38-43 (2010).
- [4] J. Wang, J. B. Neaton, H. Zheng, V. Nagarajan, S. B. Ogale, B. Liu, D. Viehland, V. Vaithyanathan, D. G. Schlom, U. V. Waghmare, N. A. Spaldin, K. M. Rabe, M. Wuttig, and R. Ramesh, *Science* **299**, 1719-1722 (2003).
- [5] C. J. Fennie and K. M. Rabe, *Physical Review B* **72**, 100103 (2005).
- [6] Y. K. Jeong, J.-H. Lee, S.-J. Ahn, S.-W. Song, H. M. Jang, H. Choi, and J. F. Scott, *Journal of the American Chemical Society* **134**, 1450 (2012).
- [7] A. Munoz, J. A. Alonso, M. J. Martinez-Lope, M. T. Casais, J. L. Martinez, and M. T. Fernandez-Diaz, *Physical Review B* **62**, 9498 (2000).
- [8] N. P. Cheremisinoff, *Handbook of Ceramics and Composites* (M. Dekker, New York, 1990).
- [9] W. Wang, H. Wang, X. Xu, L. Zhu, L. He, E. Wills, X. Cheng, D. J. Keavney, J. Shen, X. Wu, and X. Xu, *Applied Physics Letters* **101**, 241907 (2012).
- [10] M. Fiebig, D. Frohlich, K. Kohn, S. Leute, T. Lottermoser, V. V. Pavlov, and R. V. Pisarev, *Physical Review Letters* **84**, 5620 (2000).
- [11] A. A. Bossak, I. E. Graboy, O. Y. Gorbenko, A. R. Kaul, M. S. Kartavtseva, V. L. Svetchnikov, and H. W. Zandbergen, *Chemistry of Materials* **16**, 1751-1755 (2004).
- [12] E. Magome, C. Moriyoshi, Y. Kuroiwa, A. Masuno, and H. Inoue, *Japanese Journal of Applied Physics* **49**, 09ME06 (2010).
- [13] A. R. Akbashev, *Appl. Phys. Lett.* **99**, 122502 (2011).
- [14] The h-LuFeO₃ films appear to relax rapidly (see Ref. [9, 11]) Therefore, the films investigated here are all strain-relaxed.
- [15] Here we use a relatively large incident angle (3.4°) for RHEED to increase the sensitivity to the bulk part of the films.
- [16] The P6₃cm unit cell is used for the indices of crystal directions and planes of h-LuFeO₃ in the rest of the paper.
- [17] See Supplemental Material at <http://link.aps.org/supplemental/> for more detailed information of structural, ferroelectric and magnetic characterizations and analysis.
- [18] The (100) peak can not be measured for film samples grown along [001] direction by XRD because of the corresponding sample alignment orientation is not accessible.
- [19] T. Lonkai, D.G. Tomuta, U. Amann, J. Ihringer, R.W.A. Hendrikx, D.M. Tobben and J.A. Mydosh, *Physical Review B*, **69**, 134108 (2004).
- [20] M. E. Lines and A. M. Glass, *Principles and Applications of Ferroelectrics and Related Materials* (Clarendon Press, Oxford [Eng.], 1977).
- [21] S. Jesse, P. Maksymovych, and S. V Kalinin, *Applied Physics Letters* **93**, 112903 (2008).
- [22] E. F. Bertaut and M. Mercier, *Physics Letters* **5**, 27 (1963).
- [23] E. F. Bertaut, *Acta Crystallographica Section A-Crystal Physics Diffraction Theoretical and General Crystallography A* **24**, 217 (1968).
- [24] P. J. Brown and T. Chatterji, *Journal of Physics: Condensed Matter* **18**, 10085 (2006).
- [25] T. Chatterji, S. Ghosh, A. Singh, L. P. Regnault, and M. Rheinstadter, *Phys. Rev. B* **76**, 144406 (2007).
- [26] B. Roessli, S. N. Gvasaliya, E. Pomjakushina, and K. Conder, *JETP Letters* **81**, 287 (2005).
- [27] J. S. Helton, D. K. Singh, H. S. Nair, and S. Elizabeth, *Physical Review B* **84**, 64434 (2011).
- [28] Γ_2 can not be mixed with Γ_4 because it generates uneven spins on different Fe³⁺ sites. Mixing of Γ_2 with Γ_3 is also unlikely because it involves antiphase rotations of spins on different layers of Fe³⁺ sites which affects the interlayer couplings of the spins.
- [29] I. Dzyaloshinsky, *Journal of Physics and Chemistry of Solids* **4**, 241 (1958).
- [30] T. Moriya, *Physical Review* **120**, 91 (1960).
- [31] F. J. Morin, *Physical Review* **78**, 819 (1950).
- [32] D. Treves, *Journal of Applied Physics* **36**, 1033 (1965).
- [33] S. A. Klimin, M. N. Popova, B. N. Mavrin, P. H. M. van Loosdrecht, L. E. Svistov, A. I. Smirnov, L. A. Prozorova, H.-A. Krug von Nidda, Z. Seidov, A. Loidl, A. Y. Shapiro, and L. N. Demianets, *Physical Review B* **68**, 174408 (2003).
- [34] S. Mitsuda, M. Mase, T. Uno, H. Kitazawa, and H. Katori, *Journal of the Physical Society of Japan* **69**, 33 (2000).
- [35] M.L. Plumer, S.G. Condran, *Journal of Physics: Condensed Matter* **22**, 162201 (2010).
- [36] A. P. Ramirez, *Annual Review of Materials Science* **24**, 453 (1994).
- [37] H. Das, A. L. Wysocki and C. J. Fennie, *ArXiv e-prints* (2013), 1302.1099.
- [38] H. Iida, T. Koizumi, Y. Uesu, K. Kohn, N. Ikeda, S. Mori, R. Haumont, R. Janolin, P.E. Kiat, J.M. Fukunaga, Y. Noda. *J. Phys. Soc. Jpn.* **81** 024719 (2012).